

Supporting Information

Surface Passivation Strategies for CsPbBr₃ Quantum Dots Aiming at Nonradiative Suppression and Electroluminescence Light-Emitting Diodes Enhancement

Weiwei Chen^a, Lin Hu^{b*}, Yi Wang^a, Lei Huang^a, Zhen Wang^{a*}, Xiaosheng

Tang^{a*}

^aCollege of Optoelectronic Engineering, Chongqing University of Post and
Telecommunications, 400065, People's Republic of China

^bChongqing Hongyu Precision Industry Group Co., Ltd, 400799, People's Republic of
China

E-mail: 17774904172@163.com, wangzhen@cqupt.edu.cn, xstang@cqupt.edu.cn,

Received xxxxxx

Accepted for publication xxxxxx

Published xxxxxx

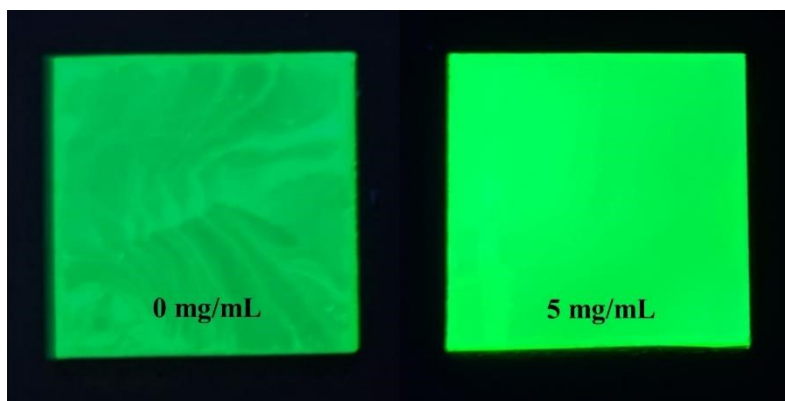


Figure S1. Display the digital images of the respective CsPbBr₃ QDs films with/without PEABr treatment under UV illumination.

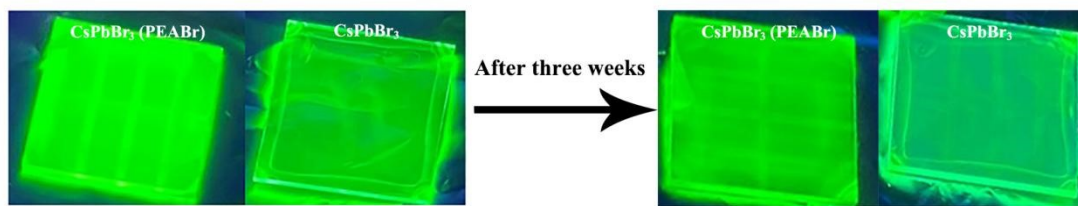


Figure S2. Change of brightness of CsPbBr₃ QDs films with/without PEABr treatment after stored three weeks under ambient environment.

Table S1. The best fit parameters of PL decay profiles for the CsPbBr₃ QD films measured at corresponding emission peak energies.

Samples	τ_1 (%)	A_1 (%)	τ_2 (%)	A_2 (ns)	τ_{avg} (ns)
0	5.2	55.4	25.3	44.6	21.21
2	6.2	39.2	29.8	60.8	27
3	6.9	33.3	31.4	66.7	28.98
5	10.8	15.7	47.2	84.3	45.71
7	7.7	25.6	33.9	74.4	32

Table S2. The radiative rate constant (k_r) and non-radiative rate constant (k_{nr}) of CsPbBr₃ QDs with different PEABr concentrations. $k_r = \text{PLQY}/\tau$, $k_{nr} = (1-\text{PLQY})/\tau$

Samples	PLQY (%)	Average Lifetime (τ , ns)	k_r (ns ⁻¹)	k_{nr} (ns ⁻¹)
0	21.9	21.21	0.01	0.037
2	31.2	27	0.012	0.025
3	40.8	28.98	0.014	0.02
5	78.6	45.71	0.017	0.005
7	47.7	32	0.015	0.016

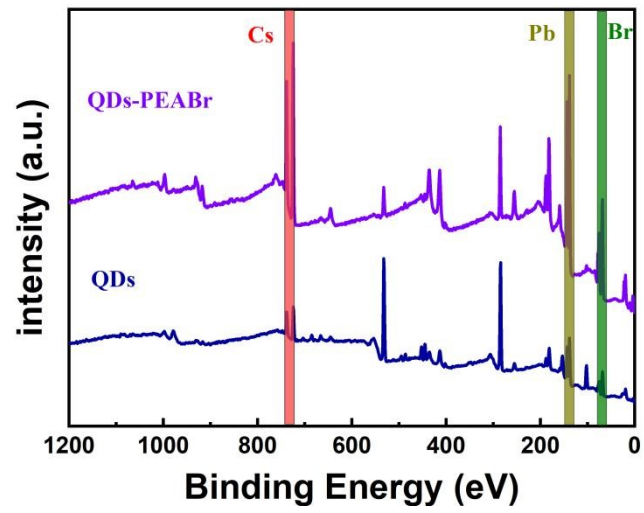


Figure. S3 Survey XPS spectra of pristine and PEABr-treated CsPbBr₃ QDs.

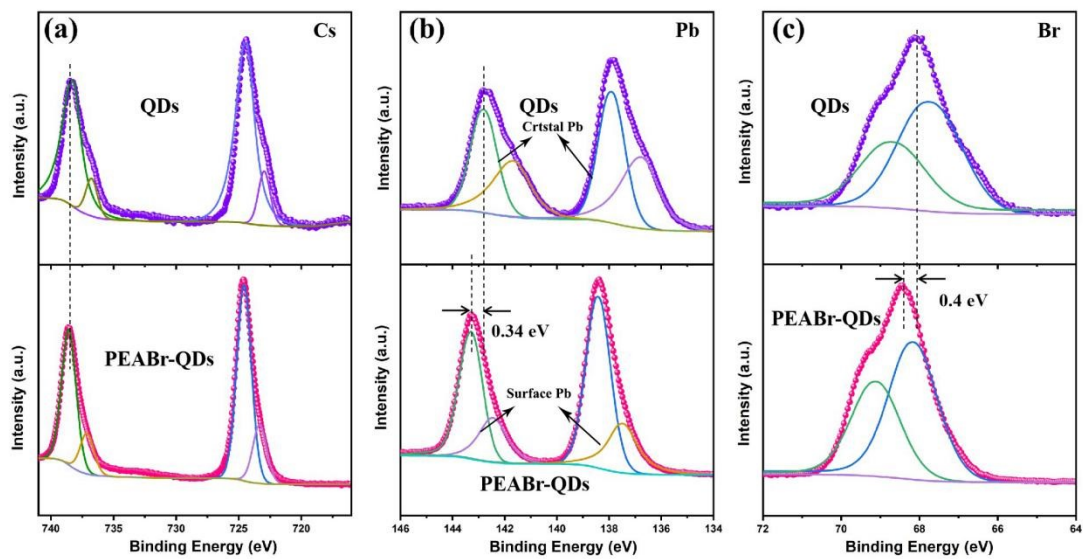


Figure. S4 Deconvolution of (a) Cs 3d, (b) Pb 4f and (c) Br 3d spectra from PEABr untreated (top) and treated (down) QDs.

Figure S5. The photograph of CsPbBr₃ QDs solution under ambient light.

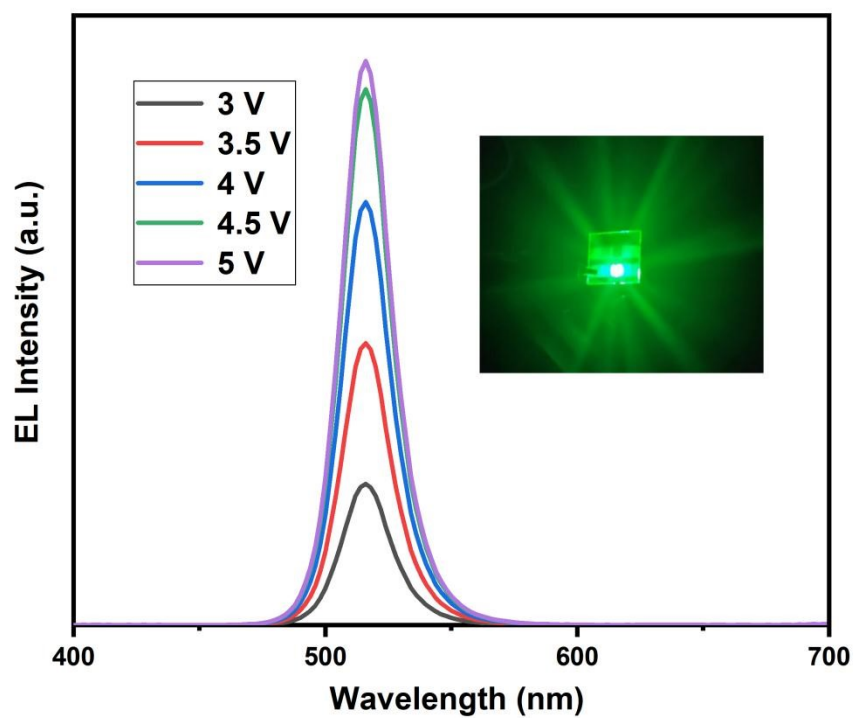


Figure S6. EL spectra of 5 wt% PEABr treated CsPbBr₃ QDs based QLED device under different driving voltage. Inset: emission image of the device with an emitting area of 3 mm×3 mm at 5.0 V.

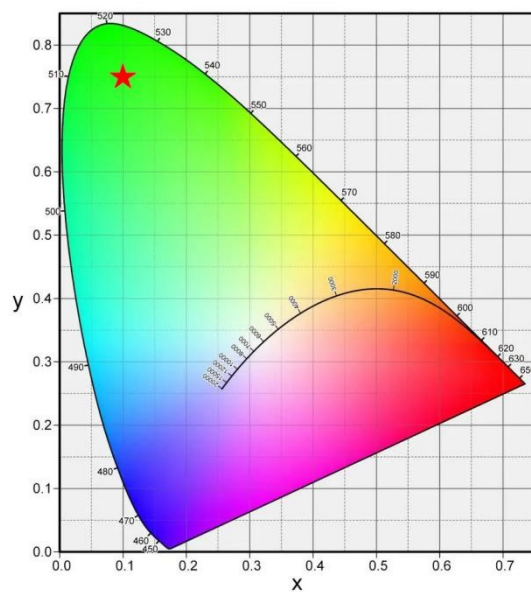


Figure S7. CIE coordinates of the PEABr treated device under an applied voltage of 5 V.

Table S3 Summary of device performance of various CsPbBr₃ QLEDs prepared with PEABr passivation.

Method	Luminance (cd m ⁻²)	CE (cd A ⁻¹)	Max EQE (%)	References
Hot-injection	13770	14.54	4.59	1
Hot-injection	12807	23.79	6.85	2
Hot-injection	12650	13.43	4.33	3
LARP	14035	32.69	9.67	This work

References

1. G. Li, J. Huang, H. Zhu, Y. Li, J. Tang, Y. Jiang, *Chem. Mater.* 2018, **30**, 6099.
2. S. He, N. Kumar, H. B. Lee, K. Ko, Y. Jung, J. I. Kim, S. Bae, J. Lee, J. Kang, *Chem. Eng. J.* 2021, **425**, 130678.
3. G. Li, J. Huang, Y. Li, J. Tang, Y. Jiang, *Nano Res.* 2019, **12**, 109.